

## CAMECA EPMA Expertise, now with Field Emission Source.

**SXFiveFE** for quantitative microanalysis and X-Ray imaging **at the highest possible spatial resolution.**

The **SXFive** is CAMECA's **fifth generation Electron Probe Microanalyser**, bringing together all the best features from the previous generation, plus reliability improvements from our automated EPMA for the semiconductor industry, control systems from our SIMS product line, a novel Field Emission source and redesigned electron column.

Our new EPMA platform is available in two configurations:

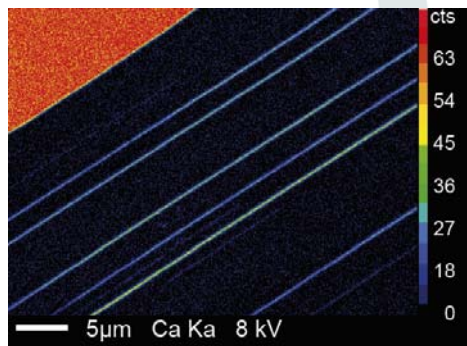
- **SXFive** with W and LaB<sub>6</sub> sources,
- **SXFiveFE** with FE source.

**Resolution**  
**Sensitivity**  
**Quantification**

CAMECA SXFiveFE



**FE Source.**  
**W & LaB<sub>6</sub>**  
also available.

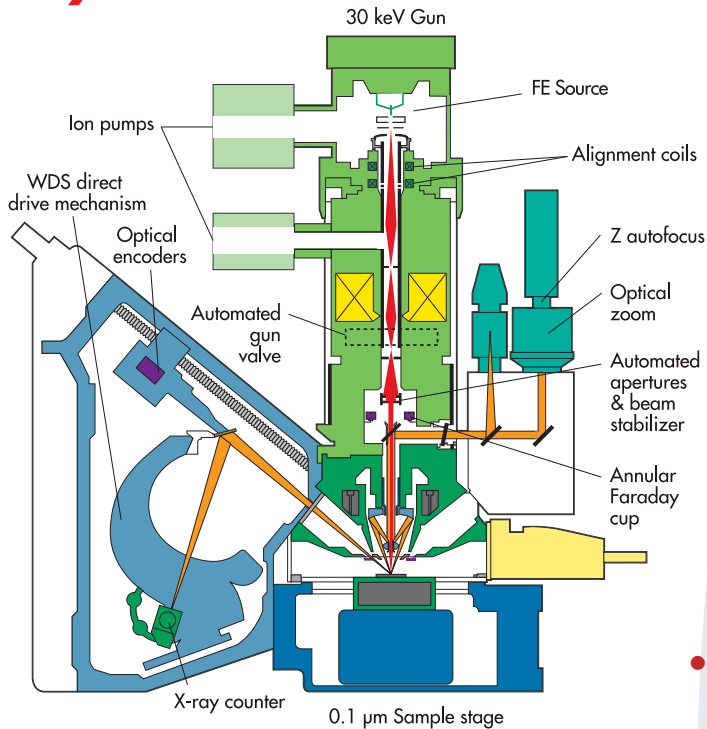


Clinopyroxene lamellae  
of few hundreds of nanometers.

Exsolution lamellae of  
clinopyroxene in orthopyroxene,  
both phases analyzed by **SXFiveFE**  
with a fully focused spot.

	Na <sub>2</sub> O	MgO	SiO <sub>2</sub>	Al <sub>2</sub> O <sub>3</sub>	CaO	FeO	MnO	Total
Cpx	0.42	16.84	52.32	1.57	25.53	3.44	0.17	100.31
Opx	0.02	30.96	54.68	1.13	0.71	11.74	0.47	99.71

# SXFiveFE



## New features:

- Field Emission source and electron optics
- Optimized vacuum system
- Enhanced automation
- Annular Faraday Cup

The **SXFiveFE** integrates mature technologies from CAMECA's SIMS and other EPMA product lines, with the latest developments in general purpose EPMA.

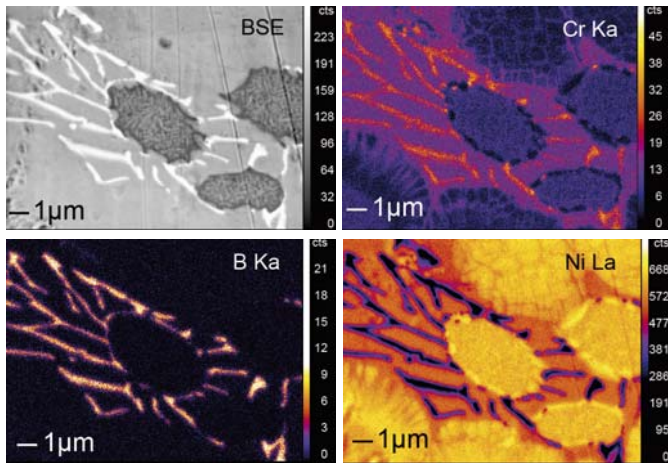
## The SXFiveFE provides:

- Quantitative analysis at **submicron scale**
- High quality **minor and trace element analysis**
- **Mapping** at high spatial resolution
- Highest precision spectrometers for **greatest reproducibility**
- Full automation for long-term **unattended analysis**

## Light element analysis and mapping at high spatial resolution

Interdiffusion of elements during the heat release between a nickel-based braze and a substrate of nickel-based superalloy.

Sample courtesy of C. Pascal, R.M. Marin-Ayral, J.C. Tédénac, C. Merlet. *Materials Science and Engineering A. Volume 341, Issues 1-2, p. 144-151.*



## X-Ray imaging at sub-micron scale

Cr and Al distribution among gamma-gamma' phases in Ni-based superalloy.

Sample courtesy of Dr.-Ing. I. Lopez-Galilea, Lehrstuhl Werkstofftechnik, Ruhr-Universität Bochum.

